

# Resource Summary Report

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## Harvard CNS Nanofabrication Facility

RRID:SCR\_009832

Type: Tool

### Proper Citation

Harvard CNS Nanofabrication Facility (RRID:SCR\_009832)

### Resource Information

**URL:** <http://harvard.eagle-i.net/i/00000130-756e-db1e-1971-4f2080000000>

**Proper Citation:** Harvard CNS Nanofabrication Facility (RRID:SCR\_009832)

**Description:** Core facility that provides the following services: Nanofabrication cleanroom and instrumentation access, instrument training, staff assistance. The Center for Nanoscale Systems' Nanofabrication Facility (CNS-NF), offers resource and staff support for fabricating and characterizing nanoscale devices and structures. The facility currently operates the 10,000 sq.ft. LISE Cleanroom with leading-edge equipment capable of electron-beam and optical lithography, physical and chemical vapor deposition, dry and wet processing, metrology, and device characterization.

**Resource Type:** access service resource, core facility, service resource

**Keywords:** fabrication

**Resource Name:** Harvard CNS Nanofabrication Facility

**Resource ID:** SCR\_009832

**Alternate IDs:** nlx\_156302

**Alternate URLs:** <http://www.cns.fas.harvard.edu/facilities/nanofabrication.php>

**Record Creation Time:** 20220129T080255+0000

**Record Last Update:** 20260805T044229+0000

### Ratings and Alerts

No rating or validation information has been found for Harvard CNS Nanofabrication Facility.

No alerts have been found for Harvard CNS Nanofabrication Facility.

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## Data and Source Information

**Source:** [SciCrunch Registry](#)

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## Usage and Citation Metrics

We have not found any literature mentions for this resource.